

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	13	(US-20010018255-\$ or US-20020195626-\$).did. or (US-5183771-\$ or US-6274906-\$ or US-6380053-\$ or US-6552394-\$ or US-6258680-\$ or US-5637514-\$ or US-5424234-\$ or US-5866460-\$ or US-5132757-\$ or US-6844252-\$ or US-5739066-\$).did.	US-PGPUB; USPAT	OR	ON	2007/01/11 12:56
S80	336	438/305.ccls. and (plural or multiple or third or plurality) near2 (region or area or doping or concentration)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 09:30
S81	123	438/174.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 09:55
S82	386	438/163.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 10:07
S83	53	438/185.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 10:38
S84	71	438/194.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 10:43
S85	290	438/230.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 10:48
S86	611	438/231.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 11:16
S87	415	438/232.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 12:04

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S88	635	438/306.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 12:46
S89	88	438/217,289,305.ccls. and (source or drain) near10 (plural or plurality or multi or multiple or sequential or several) near5 implant\$5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 13:28
S90	579	438/217,289,305.ccls. and (source or drain) near6 (implant\$4 or diffus\$4) near6 (sidewall or side near wall or spacer or conformal or wall) and (fet or mos or mosfet or nmos or pmos or cmos or transistor)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 13:41
S91	408	438/217,289,305.ccls. and (ldd or lightly near doped near drain or drain near extension or source near extension) near10 implant\$5 near10 (sidewall or side near wall or spacer or edge)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 14:04
S92	791	438/217,289,305.ccls. and (source or drain or impurity) near6 (implant\$4 or diffus\$4) near6 (sidewall or side near wall or spacer or conformal or wall)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/01/08 14:28